

## **ELECTRONIC INFORMATION DISCLOSURE STATEMENT**

Electronic Version v18 Stylesheet Version v18.0

> Title of Invention

METHOD AND APPARATUS USING INTERFEROMETRIC METROLOGY FOR HIGH ASPECT RATIO INSPECTION

Application Number:

10/672298

Confirmation Number:

4459

First Named Applicant:

Shiow-Hwei Hwang

Attorney Docket Number: KLA1P067/P995

Art Unit:

2621

Search string:

( 4818110 or 6262818 or 6078392 ).pn.

## **US Patent Documents**

Note: Applicant is not required to submit a paper copy of cited US Patent Documents

init	Cite.No.	Patent No.	Date	Patentee	Kind	Class	Subclass
CA	1	4818110	1989-04-04	Davidson		356	358
PIL	2	6262818	2001-07-17	Cuche et al.		359	
m	3	6078392	2000-06-20	Thomas et al.		356	457

## Signature

Examiner Name	Date		
PARICY CONDOLLY	11-14 2005		